	Application No.	Applicant(s)
Aladiaa af Allawahilitu	10/767,430	SHINO, TOMOAKI
Notice of Allowability	Examiner	Art Unit
	Andy Huynh	2818
The MAILING DATE of this communication app All claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85 NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT F of the Office or upon petition by the applicant. See 37 CFR 1.31	S (OR REMAINS) CLOSED  5) or other appropriate comm  RIGHTS. This application is	in this application. If not included nunication will be mailed in due course. <b>THIS</b>
1. X This communication is responsive to the Election dated 0	<u>06/02/2005</u> .	
2. The allowed claim(s) is/are <u>1-16</u> .	•	·
3. $\boxtimes$ The drawings filed on <u>30 January 2004</u> are accepted by t	he Examiner.	
<ul> <li>4.  Acknowledgment is made of a claim for foreign priority to a)  All b)  Some* c)  None of the: <ol> <li>Certified copies of the priority documents have</li> <li>Certified copies of the priority documents have</li> <li>Copies of the certified copies of the priority documents have</li> <li>International Bureau (PCT Rule 17.2(a)).</li> </ol> </li> <li>* Certified copies not received: <ol> <li>Applicant has THREE MONTHS FROM THE "MAILING DATE noted below. Failure to timely comply will result in ABANDON THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.</li> </ol> </li> </ul>	ve been received. ve been received in Application ocuments have been received. " of this communication to file	ion No ed in this national stage application from the
5. A SUBSTITUTE OATH OR DECLARATION must be subminformal PATENT APPLICATION (PTO-152) which gives		
<ul> <li>CORRECTED DRAWINGS ( as "replacement sheets") muse (a) including changes required by the Notice of Draftsper 1) hereto or 2) to Paper No./Mail Date (b) including changes required by the attached Examine Paper No./Mail Date (like including changes required by the attached Examine Paper No./Mail Date (like including indicia such as the application number (see 37 CFR each sheet. Replacement sheet(s) should be labeled as such in 7. DEPOSIT OF and/or INFORMATION about the departached Examiner's comment regarding REQUIREMENT</li> </ul>	rson's Patent Drawing Revie r's Amendment / Comment of  1.84(c)) should be written on the header according to 37 C osit of BIOLOGICAL MAT	or in the Office action of the drawings in the front (not the back) of FR 1.121(d). FERIAL must be submitted. Note the
<ul> <li>Attachment(s)</li> <li>1.  Notice of References Cited (PTO-892)</li> <li>2.  Notice of Draftperson's Patent Drawing Review (PTO-948)</li> <li>3.  Information Disclosure Statements (PTO-1449 or PTO/SB. Paper No./Mail Date 04/22/2004</li> <li>4.  Examiner's Comment Regarding Requirement for Deposit of Biological Material</li> </ul>	) 6. ☐ Interview 9 Paper No /08), 7. ☒ Examiner	nformal Patent Application (PTO-152) Summary (PTO-413),  Mail Date s Amendment/Comment  S Statement of Reasons for Allowance  Andy Huynh Patent Examine  BY 2818

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### **DETAILED ACTION**

## Election/Restrictions

In the Response to Restriction Requirement dated March 09, 2005, Applicant has elected the invention of Group I (claims 1-16), drawn to a device. Because Applicant did not distinctly and specifically point out the supposed error in the restriction requirement, the election has been treated as an election without traverse (MPEP § 818.03(a)). Accordingly, claims 17-20 are withdrawn from consideration as being directed to a non-elected invention. See 37 CFR 35 § 1.142(b) and MPEP § 821.03. Applicant has the right to file a divisional application covering the subject matter of the non-elected claims 17-20.

## Examiner's Amendment

An examiner's amendment to the record appears below. Should the changes and/or additions be unacceptable to applicant, an amendment may be filed as provided by 37 CFR 1.312. To ensure consideration of such an amendment, it MUST be submitted no later than the payment of the issue fee.

The application has been amended as follows:

The title of the invention has been changed as follows:

-SEMICONDUCTOR DEVICE INCLUDING TRANSISTORS
FORMED IN SEMICONDUCTOR LAYER HAVING SINGLE-CRYSTAL
STRUCTURE ISOLATED FROM SUBSTRATE--.

This application is in condition for allowance except for the presence of claims 17-20 non-elected without traverse. Accordingly, claims 17-20 have been canceled.

# Allowable Subject Matter

Claims 1-16 are allowed.

The following is an examiner's statement of reason for allowance:

Claims 1-14 are allowable over the prior art of record because the prior art of record does not teach or render obvious a semiconductor device comprises a second gate electrode having a gate length larger than a onefold value of a gate length of a first gate electrode and yet less than or equal to thrice the gate length, and a second gate line is placed between portions of a dielectric layer underlying a pair of impurity regions, and in combination with all other features as recited in independent claim 1.

Claim 15 is allowable over the prior art of record because the prior art of record does not teach or render obvious a semiconductor device comprises, in combination with all other features, a second gate line is placed between portions of a dielectric layer underlying a pair of impurity regions and an isolation portion having a bottom positioned at a lower level than a semiconductor layer.

Claim 16 is allowable over the prior art of record because the prior art of record does not teach or render obvious a semiconductor device comprises, in combination with all other features, a second gate line is placed between portions of a dielectric layer underlying a pair of impurity regions wherein a semiconductor layer is such that a formation region of a channel body is less in thickness than a formation region of the impurity region.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue

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fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance".

### Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Andy Huynh whose telephone number is (571) 272-1781. The examiner can normally be reached on Monday-Friday 8:30am-5:00pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, David Nelms can be reached on (571) 272-1787. The fax phone numbers for the organization where this application or proceeding is assigned are (703) 872-9306 for regular communications and (703) 872-9306 for After Final communications.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is (703) 308-0956.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

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06/09/05

Andý Huynh

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Patent Examiner